



# TEST OF SILICON SENSORS FOR LUXE

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AIDAINNOVA 3<sup>RD</sup> ANNUAL MEETING

# SENSORS

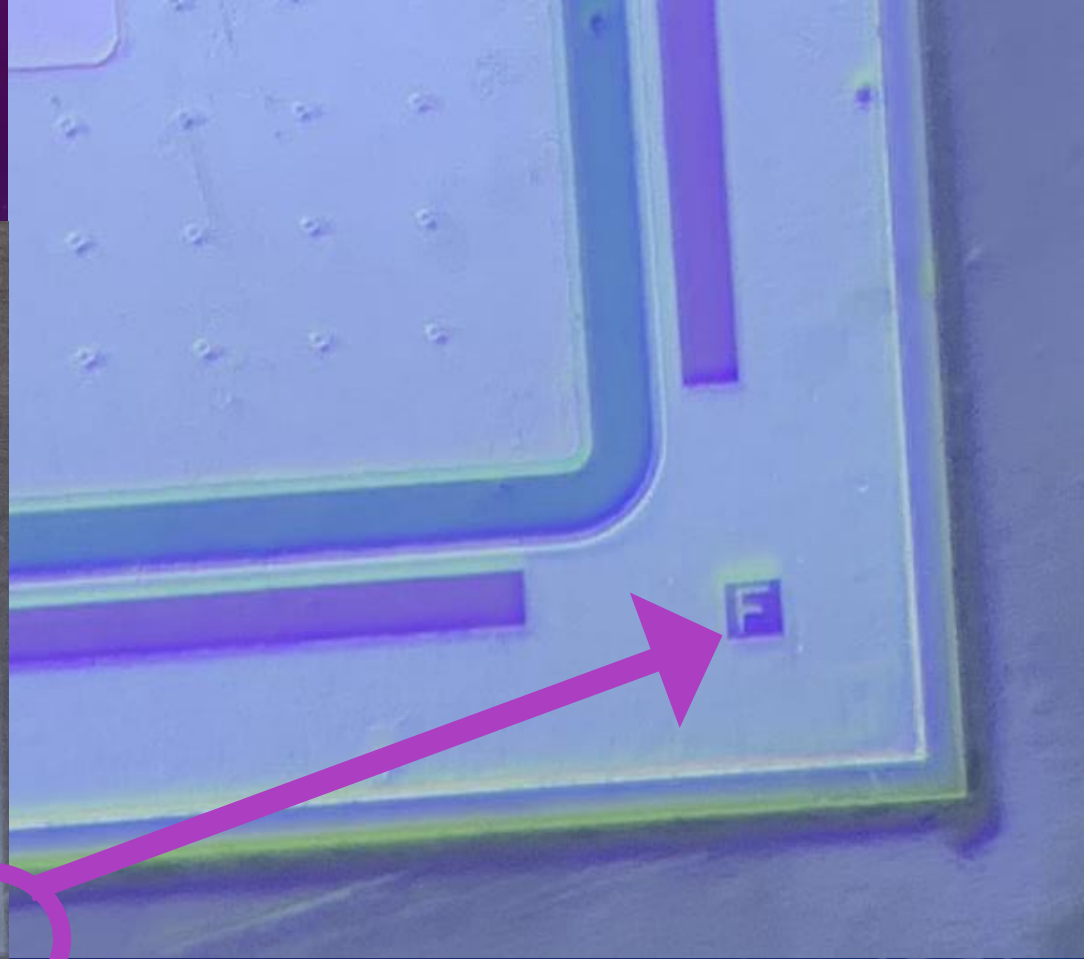
- 90 CALICE sensors received from Hamamatsu. 320 um thickness, 16x16 pads (5.5x5.5 mm<sup>2</sup>)
- Labeled and stored in dry cabinet with membrane boxes

Parameter	Rating	Unit
Device type	P+ PIXEL on N substrate	
Chip size	89700 ± 40 x 89700 ± 40	μ m
Active area	88480 x 88480	μ m
Chip thickness	320 ± 15	μ m
Number of PIXELs	256(16 x 16)	ch
PIXEL pitch	5530 x 5530	μ m
PIXEL GAP	10	μ m

Parameter	Symbol	Condition	Min	Typ	Max	Unit
substrate resistitance			3	---	---	kΩ · cm
Full depletion voltage	Vfd		15	---	120	V
leakage current(for inner PIXEL*2)	Id	VR=200V	---	---	25	nA
leakage current(for outer PIXEL*2)	Id2	VR=200V	---	---	100	nA
Number of NG PIXEL			---	---	10	ch

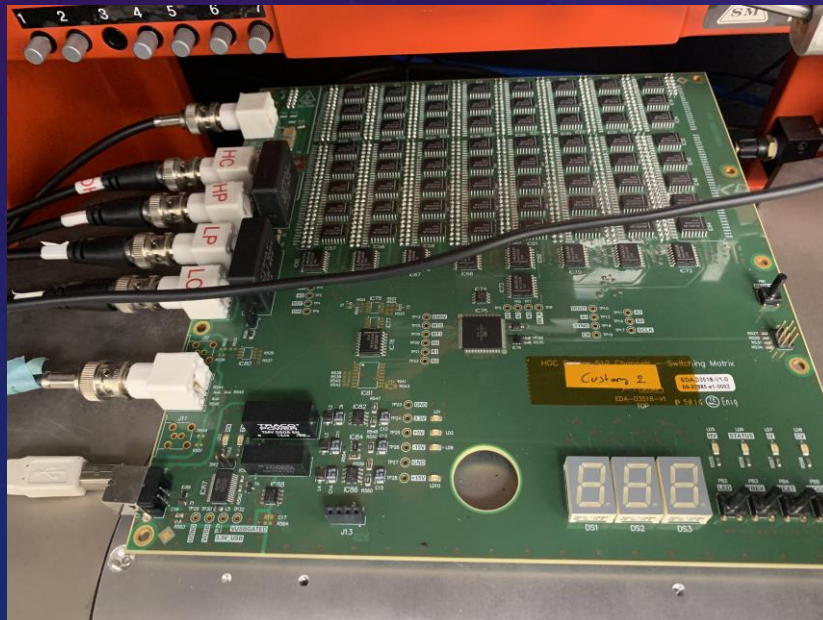


# SENSORS



# PROBE STATION

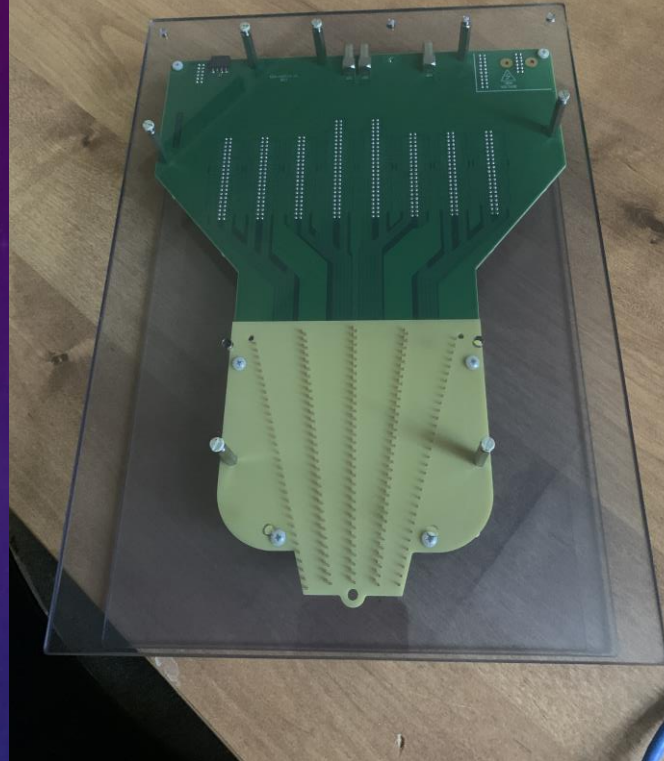
- The manual probe station has been donated by DESY Zeuthen 15 years ago. It has been automatized by adding a switch card connected to a probe card (sensor design dependent) developed at CERN
- Originally designed for lumical sensors



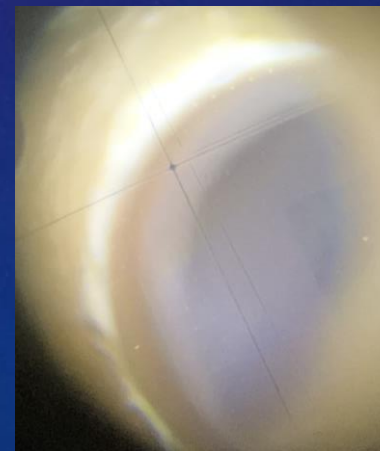
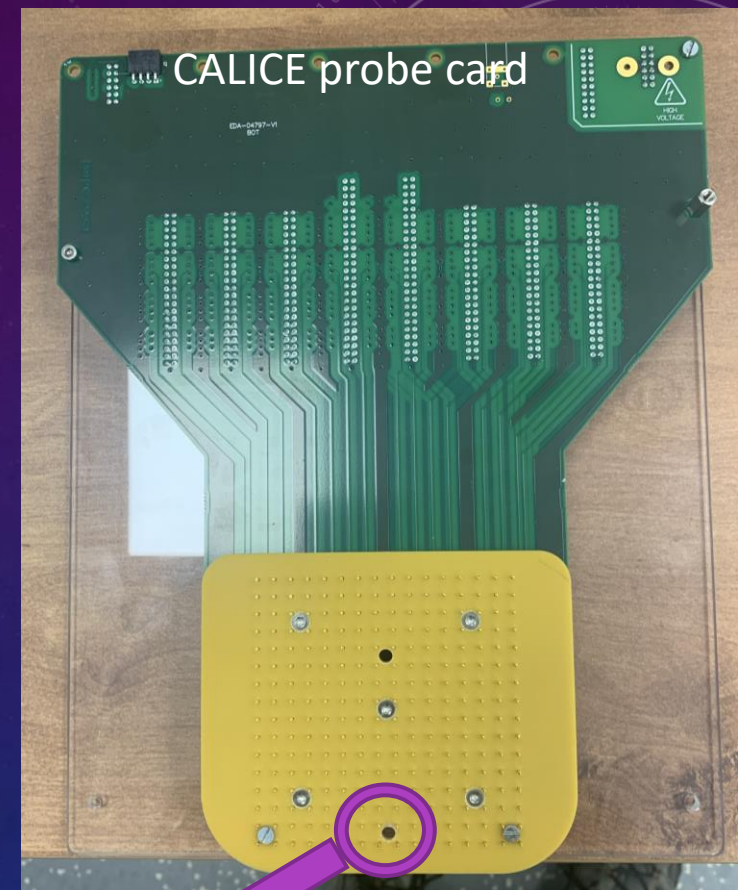
# PROBE STATION

- CALICE probe card arrived
- Probe station updated to accept the new probe card. Cooling, gas, pump cleaned and working
- Software updated for the new probe card (configuration files)

Lumical probe card



CALICE probe card

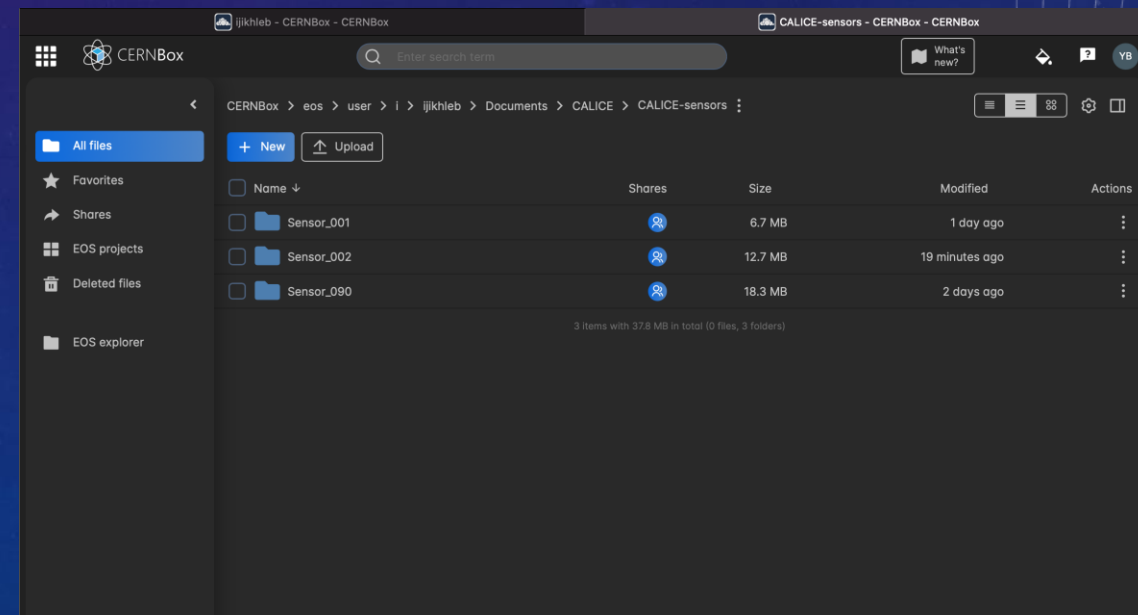


# SENSOR DATA

- Data from the probe station are saved on the local computer
- Then transferred to the CERN cloud (CERNBOX accessible by the collaboration)
- Analyzed by python soft to produce plots and alarm if needed
- For each sensor, one excel file produced with 256 sheets containing plots (CV,IV) for each pad. The excel file is uploaded to the CERN cloud.

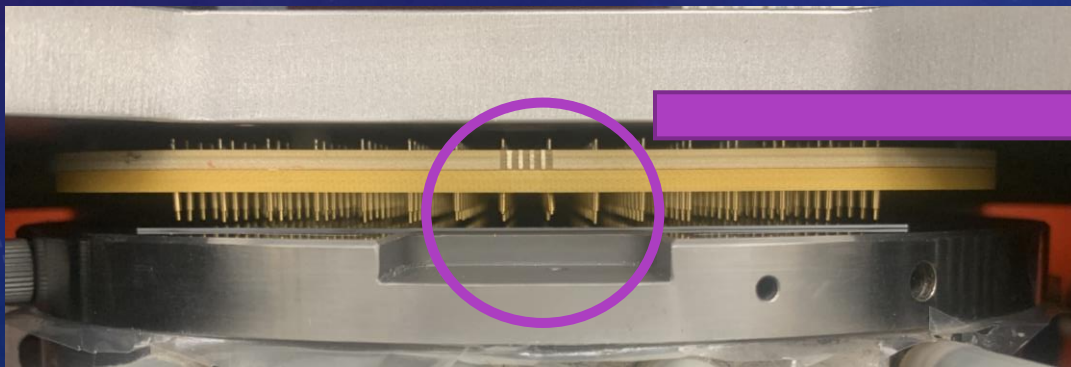
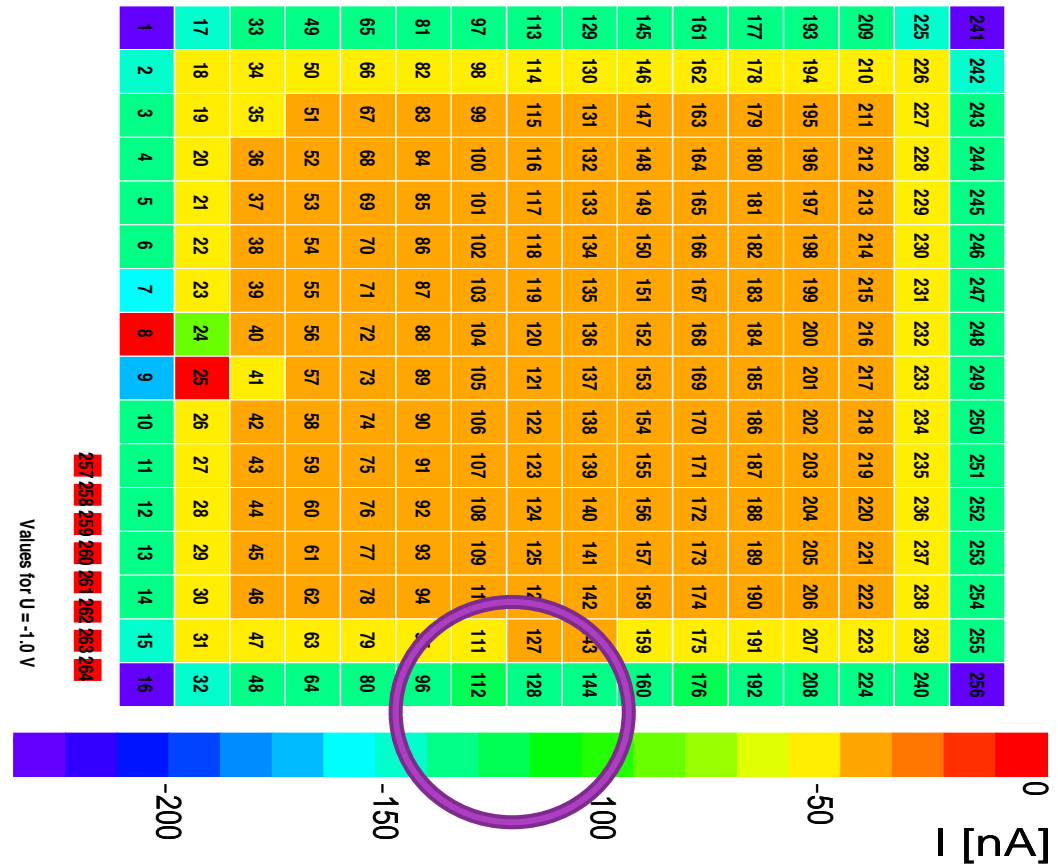
## Sensors and infrastructure :

- All sensors arrived and stored in good conditions
- Probe station has been modified and ready to test
- Data are saved and shared with the collaboration



# DATA TAKING

- 1<sup>st</sup> step : contact test to be sure all the pads are touching the probe pins. Takes few minutes
- 2<sup>nd</sup> step IV test.
- 3<sup>rd</sup> step CV test.
- We are adding the following steps :
  - Rotation of the sensors (90 degrees)
  - Contact test
  - IV and CV for the missing pins



# IV MEASUREMENT

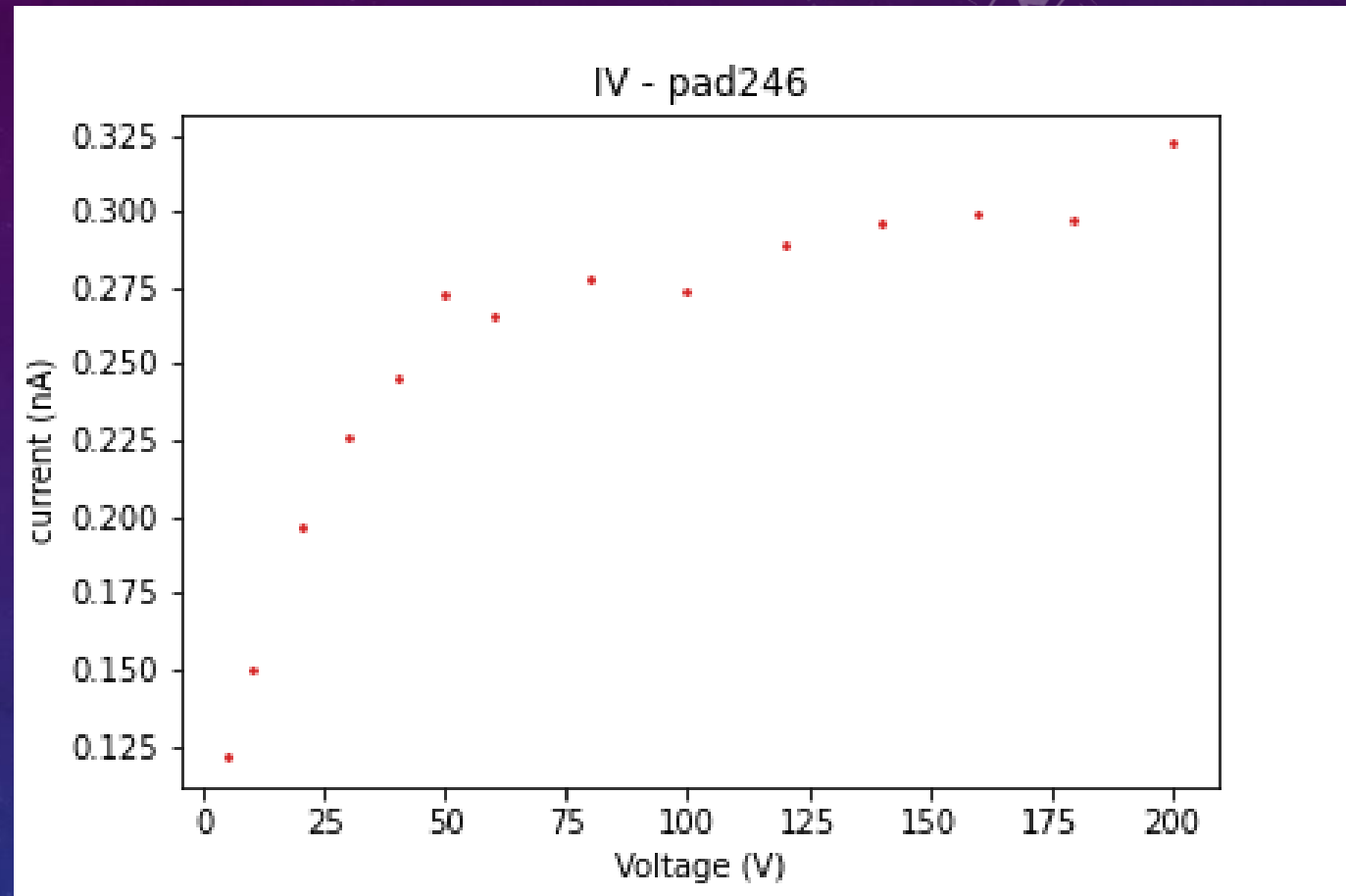
Checked the influence of different parameters:  
delay between measurements, delay between  
voltage change,...



System tuned



Up to now, 25 x 256 pads measured  
with current plateau

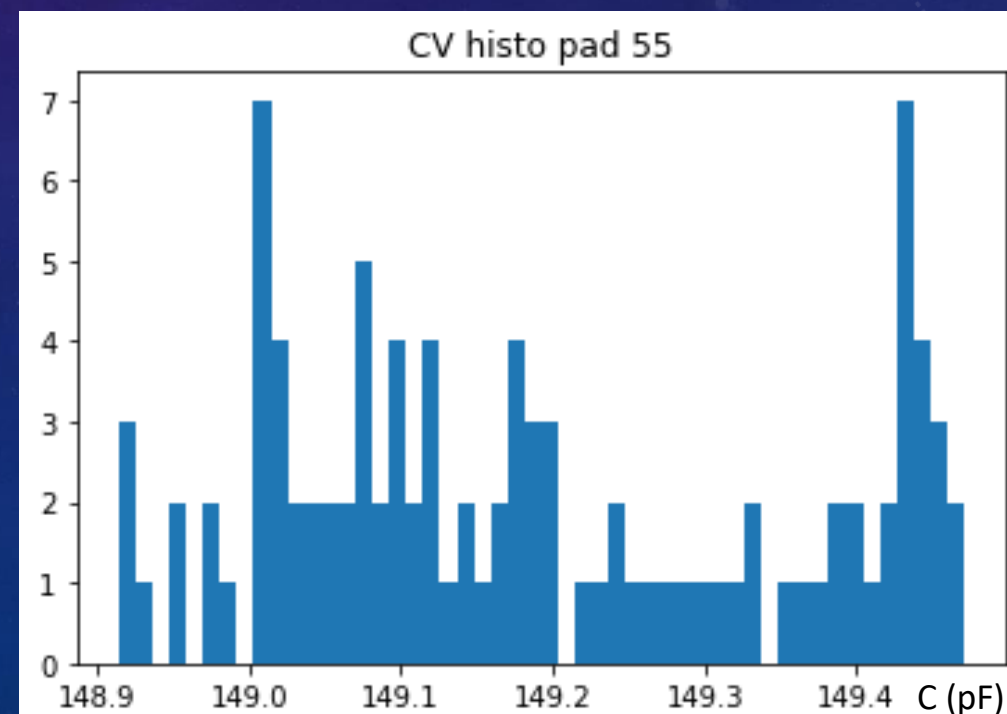
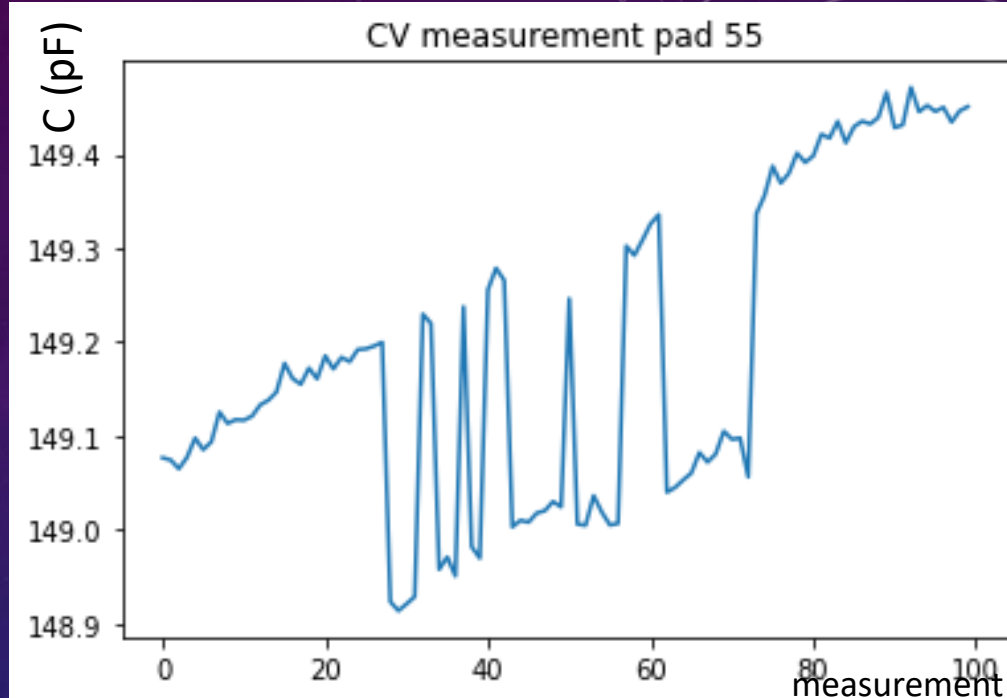
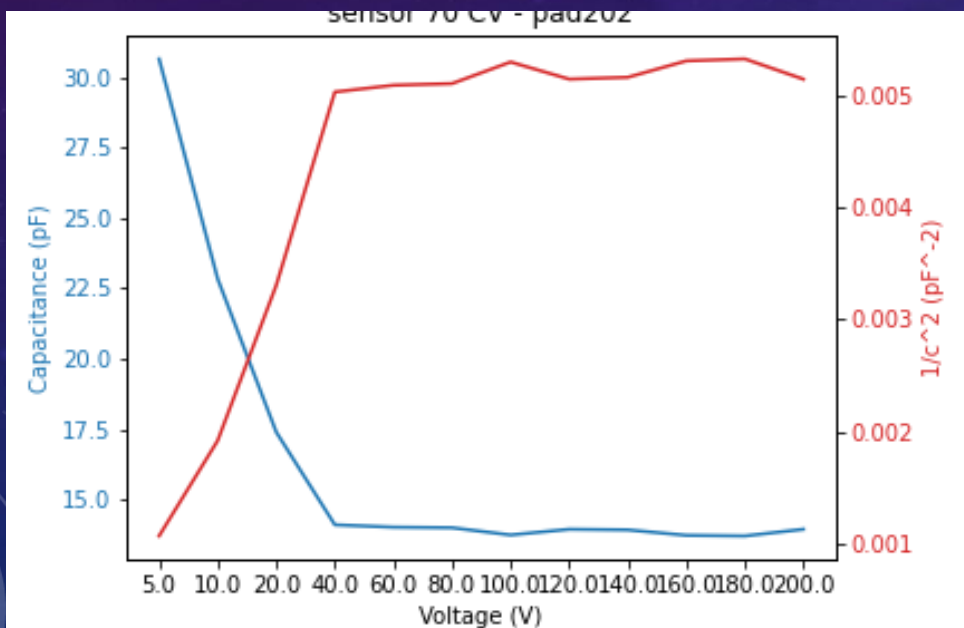




# CV MEASUREMENT

- 100 CV measurement on the same pad to check the repeatability
- Measurement of the system every 10 CV measurements (to be subtracted)

$$\text{Capacitance}_{\text{sensor}} = C_{\text{measured}} - C_{\text{station}}$$

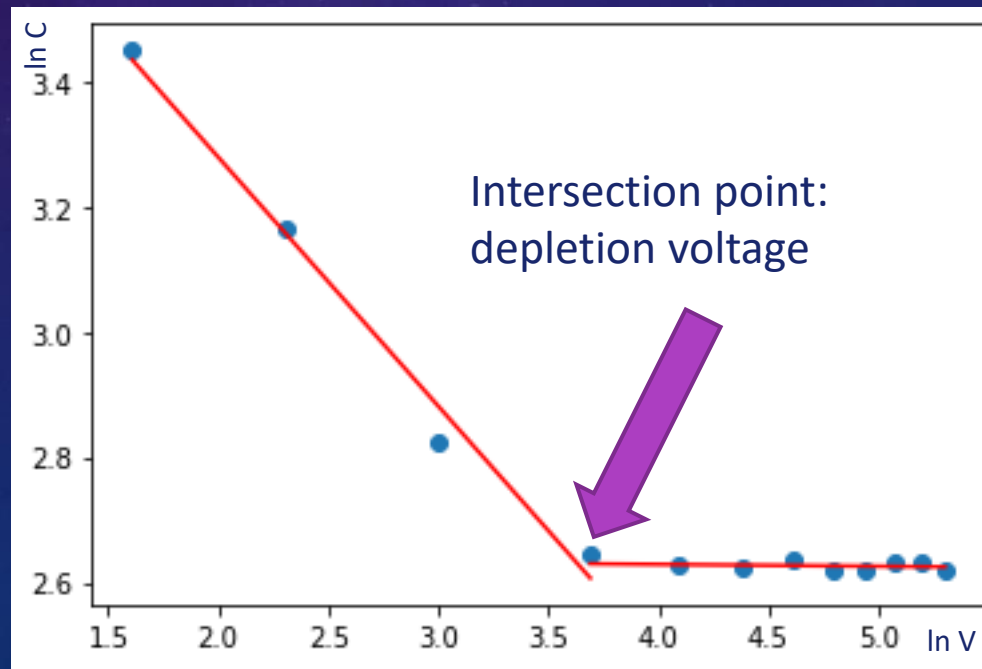


# DEPLETION VOLTAGE

- It is possible to extract the depletion voltage from the CV measurement; the capacitance can be modeled by:

$$C_g = A \frac{\epsilon_{Si} \epsilon_0}{w} = \begin{cases} A \sqrt{\frac{\epsilon_{Si} \epsilon_0 e N_d}{2V}} & \text{for } V < V_d, A: \text{pad area } N_d : \text{number of donor, } V \text{ bias voltage} \\ A \frac{\epsilon_{Si} \epsilon_0}{w_m} & \text{for } V > V_d, w_m \text{ max. depletion width} \end{cases}$$

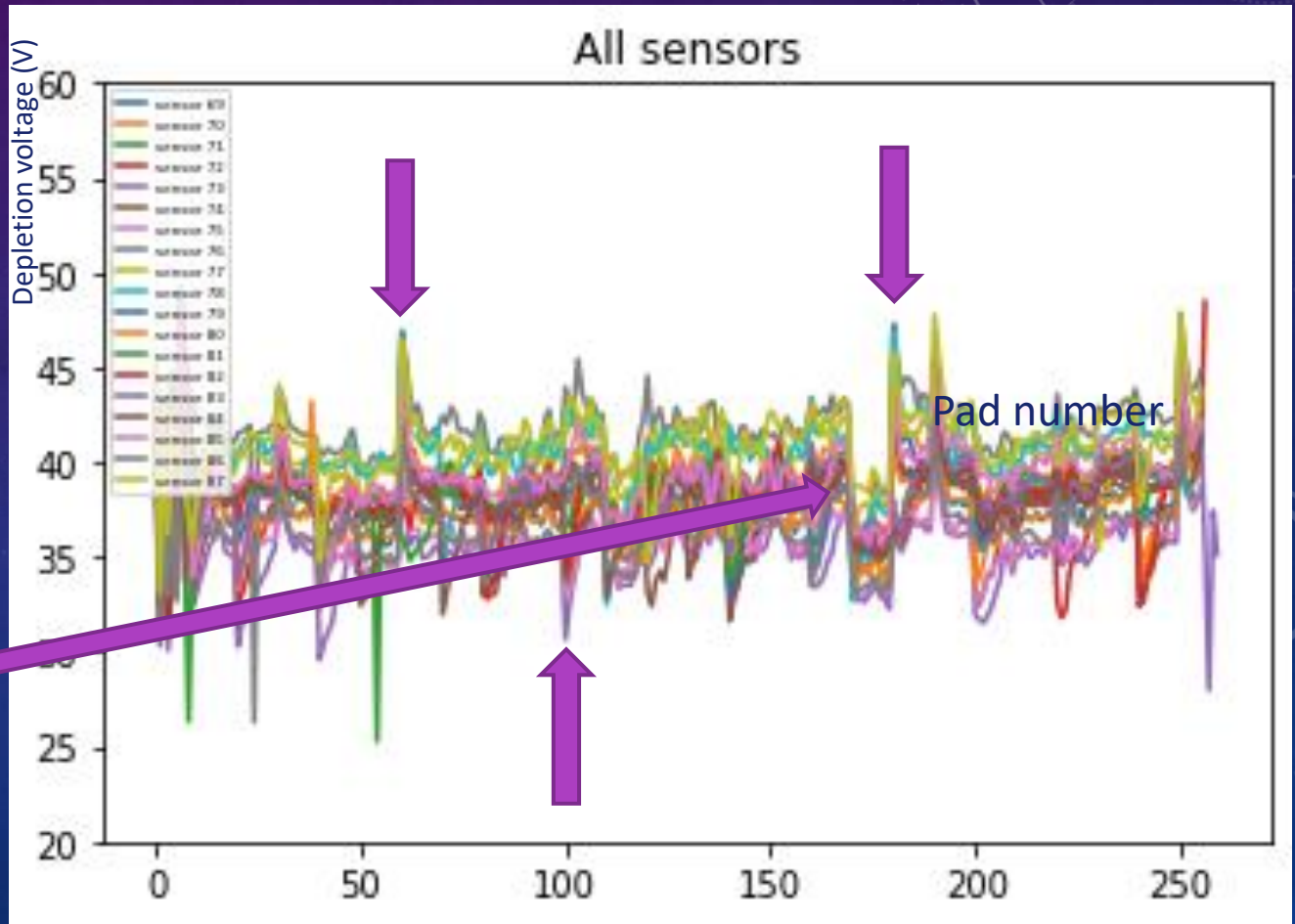
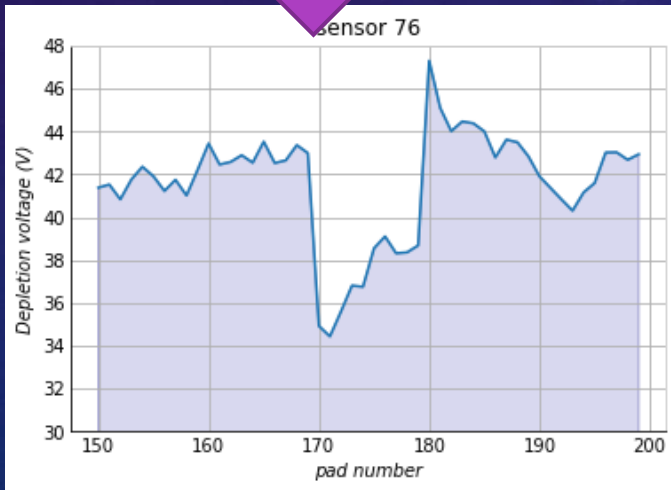
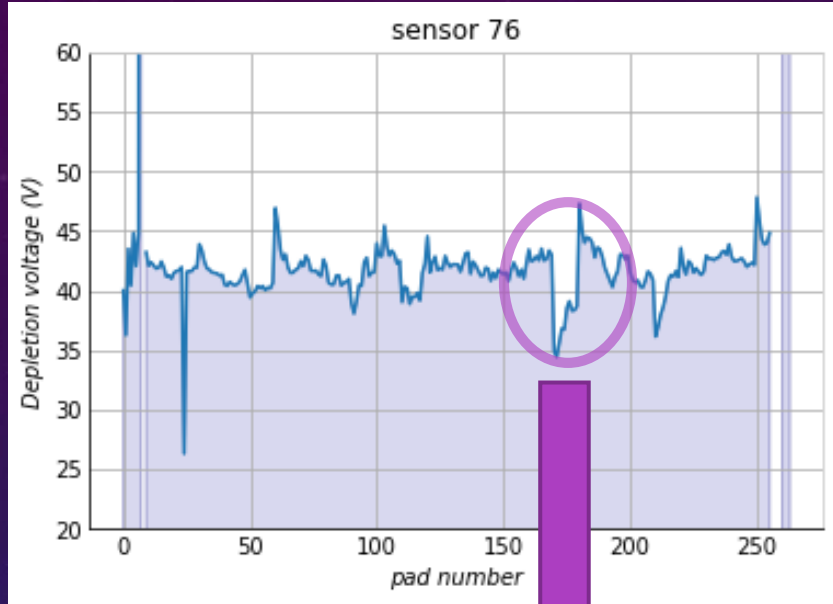
- So if we take the log of  $C_g$ , we should obtain two lines. The intersection of these lines is giving the depletion voltage



# DEPLETION VOLTAGE

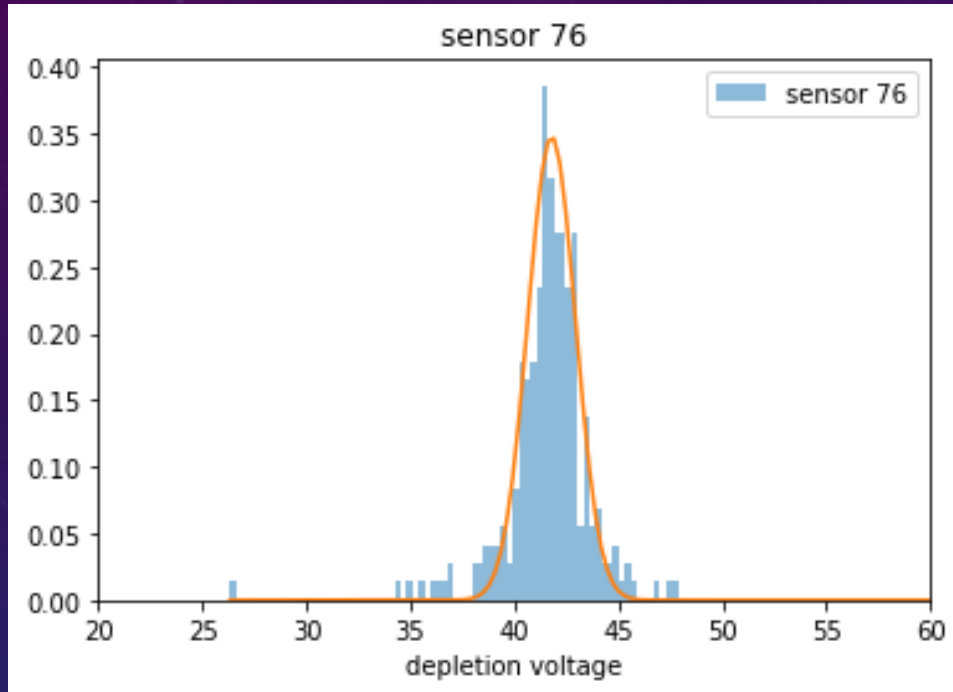
- Define the depletion voltage per pad :

241	242	243	244	245	246	247	248	249	250	251	252	253	254	255	256
225	226	227	228	229	230	231	232	233	234	235	236	237	238	239	240
209	210	211	212	213	214	215	216	217	218	219	220	221	222	223	224
193	194	195	196	197	198	199	200	201	202	203	204	205	206	207	208
177	178	179	180	181	182	183	184	185	186	187	188	189	190	191	192
161	162	163	164	165	166	167	168	169	170	171	172	173	174	175	176
145	146	147	148	149	150	151	152	153	154	155	156	157	158	159	160
129	130	131	132	133	134	135	136	137	138	139	140	141	142	143	144
113	114	115	116	117	118	119	120	121	122	123	124	125	126	127	128
97	98	99	100	101	102	103	104	105	106	107	108	109	110	111	112
81	82	83	84	85	86	87	88	89	90	91	92	93	94	95	96
65	66	67	68	69	70	71	72	73	74	75	76	77	78	79	80
49	50	51	52	53	54	55	56	57	58	59	60	61	62	63	64
33	34	35	36	37	38	39	40	41	42	43	44	45	46	47	48
17	18	19	20	21	22	23	24	25	26	27	28	29	30	31	32
1	2	3	4	5	6	7	8	9	10	11	12	13	14	15	16

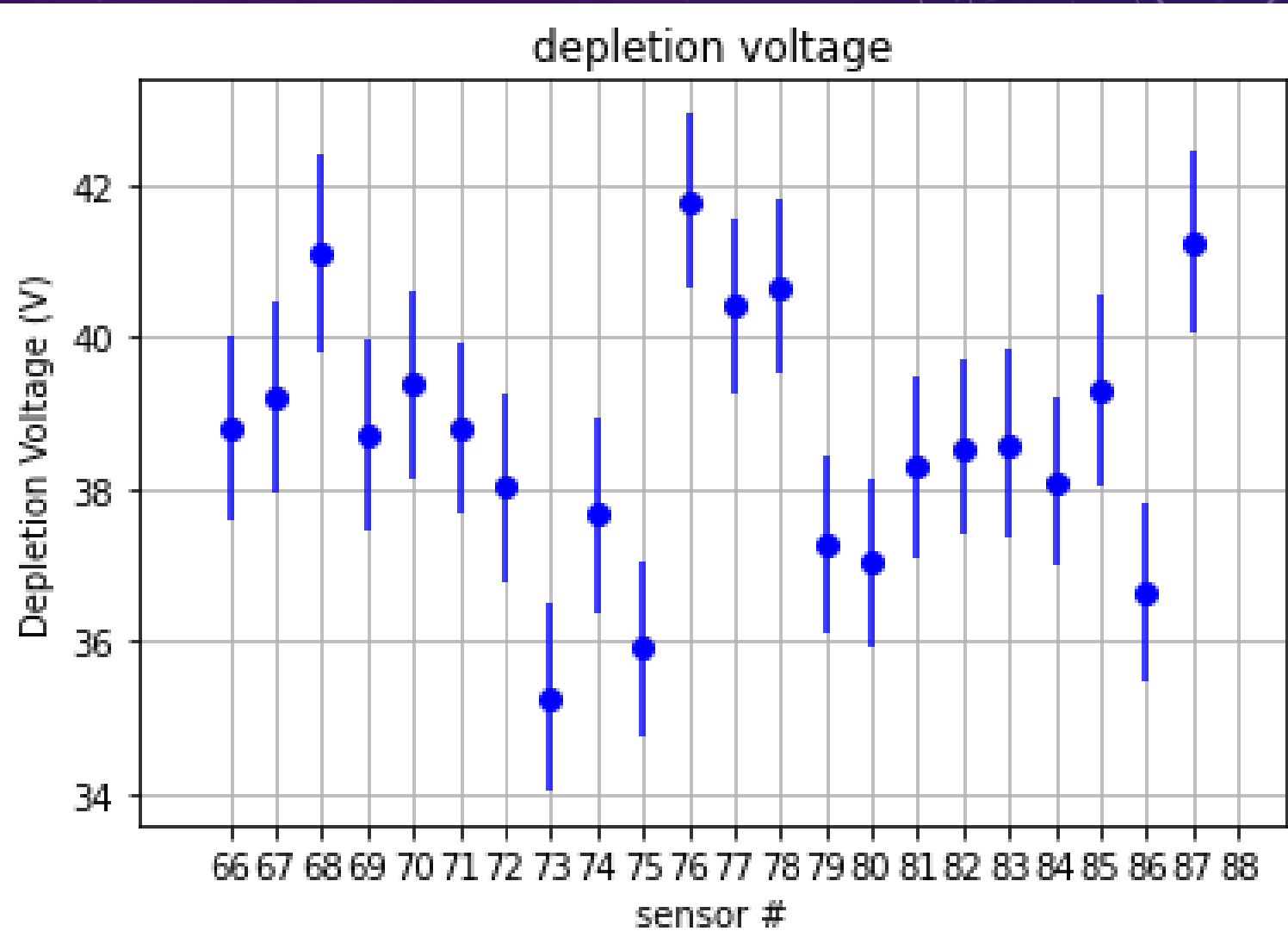


# DEPLETION VOLTAGE

- Fit per sensor -> mean, sigma



This corresponds to the expected values

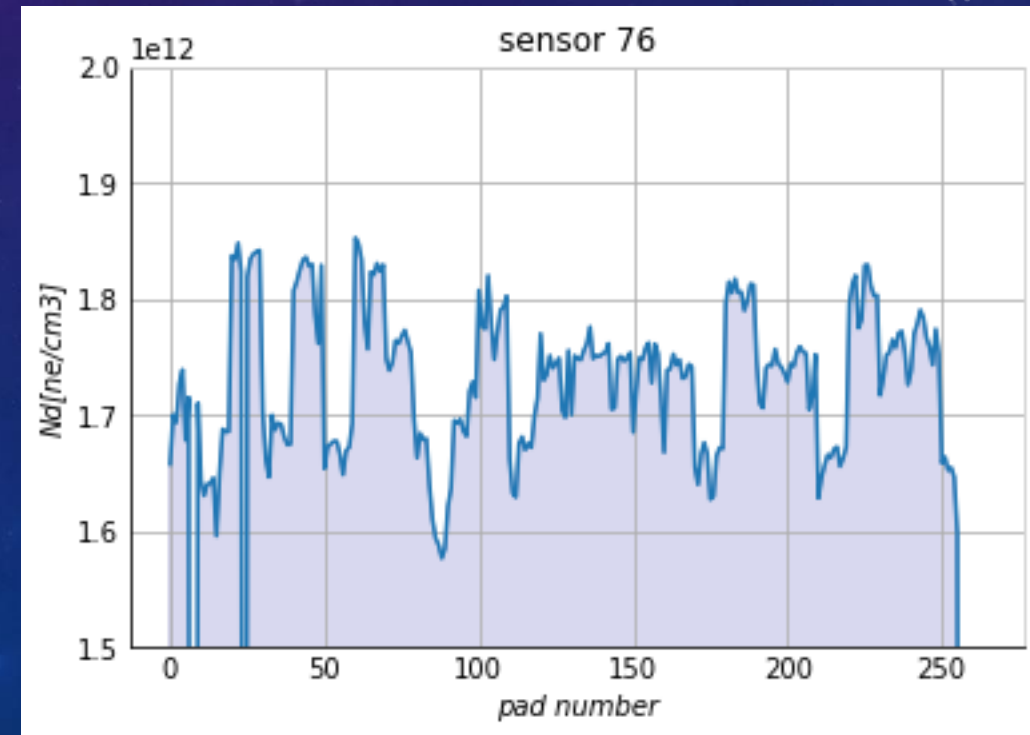
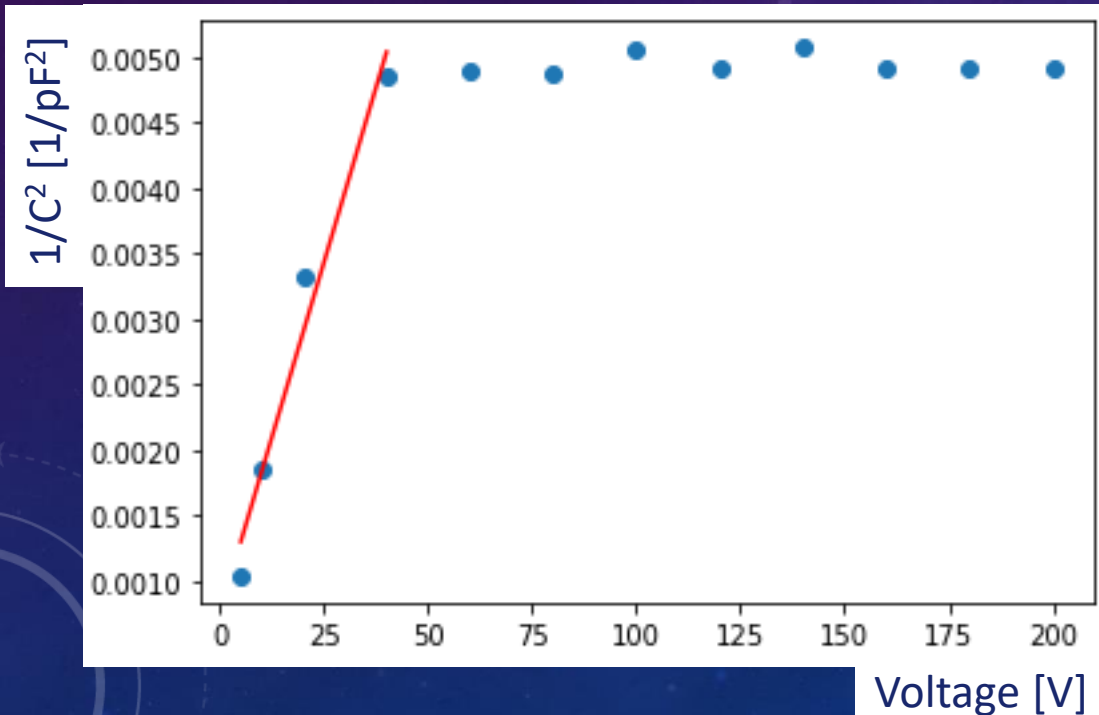


# DONOR DENSITY

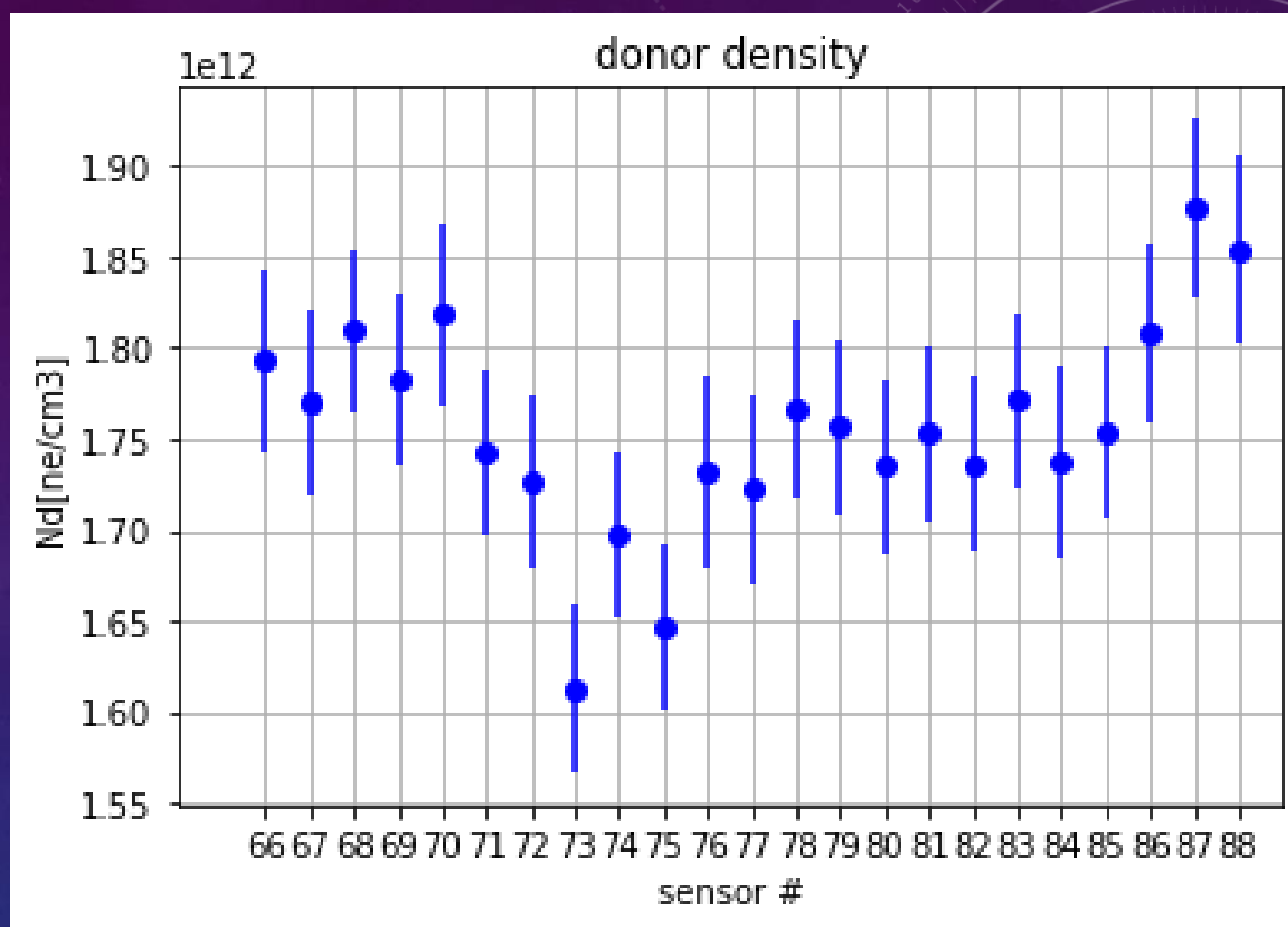
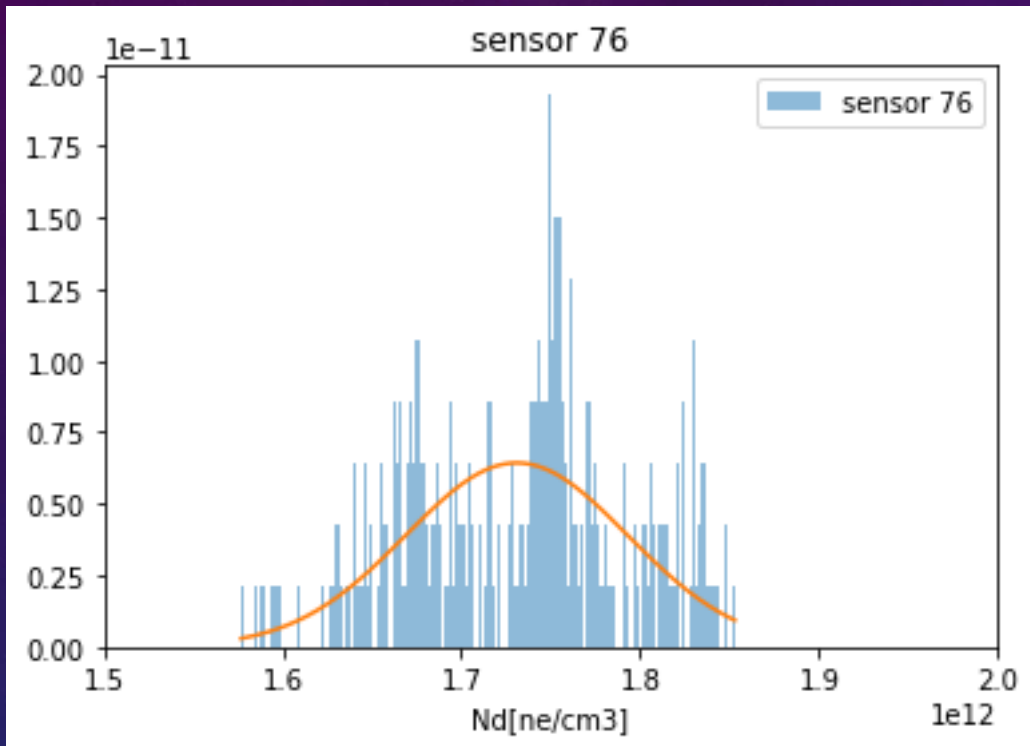
- It is possible to determine the donor density using the formula :

$$\frac{1}{C^2} = \frac{2}{\epsilon\epsilon_0 N_d A^2} V$$

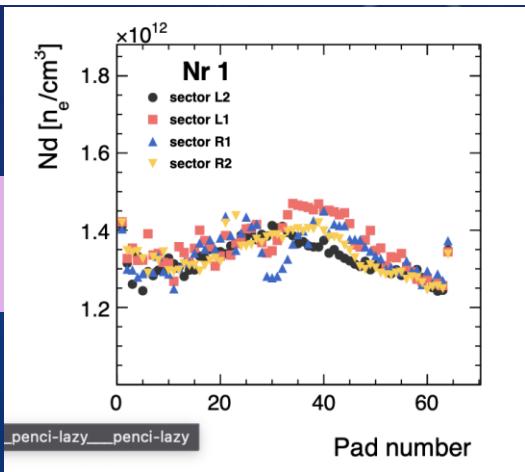
Where  $N_d$  is the donor density and  $A$  is the pad area



# DONOR DENSITY



This is compatible with the values found with lumical sensor



# CONCLUSION

- We have a working setup to characterize silicon sensors, including analysis and storage : we can test two sensors a day (without the rotation)
- All the pads of the tested sensors have a plateau in the IV plot
- Using the CV measurement, it is possible to extract the depletion voltage and the donor density. These extracted values are compatible with expectations

THANKS

